

### **REMARKS**

Claims 1-2 and 4-9 are pending in this application. Claims 1, 5, 7 and 8 have been amended. It is respectfully submitted that no new matter has been added by the present amendment.

#### **Rejections under 35 U.S.C § 102:**

Claims 1, 2 and 4-9 stand rejected under 35 U.S.C § 102 (b) as being anticipated by Kim et al. (US Patent 6,100,954).

Amended claims 1, 5, 7 and 8 recite, *inter alia*, that at least one of the gate insulating layer and the passivation layer is made at least one of Parylene N, Parylene C or Parylene D. Applicants respectfully submit that Kim does not disclose the above-claimed features.

The Examiner states Kim discloses that “at least one of the gate insulating layer and the passivation layer is made of Parylene (column 15, lines 14-23).” However, Kim discloses using fluorinated parylene (known as “Parylene F”) to form a gate insulation layer. See e.g., col. 15, lines 14-23 of Kim. As such, Kim does not disclose that at least one of the gate insulating layer and the passivation layer is made at least one of Parylene N, Parylene C or Parylene D.

Thus, claims 1, 5, 7 and 8 are not anticipated by Kim. As claims 2 and 4 depend from claim 1, claim 6 depends from claim 5, and claim 9 depends from 8, they are also not anticipated by Kim due at least to their dependency on the respective base claim.

Based on the arguments above, reconsideration and withdrawal of the rejection of claims 1, 2 and 4-9 under 35 U.S.C § 102 (b) is respectfully requested.

For the foregoing reasons, the present application is believed to be in condition for allowance. The Examiner's early and favorable action is respectfully requested. The Examiner is invited to contact the undersigned if he has any questions or comments in this matter.

Respectfully submitted,



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